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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of: §

Yair EIN-ELI et al §

Serial No.: 10/750,969 §

Filed: January 5, 2004 §

Group Art Unit: 1742

For: TEXTURING A  
SEMICONDUCTOR MATERIAL  
USING NEGATIVE POTENTIAL  
DISSOLUTION (NPD) §

Attorney Docket: 27054

Examiner: Nicholas A. Smith §

Mail Stop: Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**ELECTION**

Sir:

Further to the Election filed March 1, 2007, Applicants elect **species 4, a method of texturing an unmasked unpolished semiconductor material.**

**Claims 17, 20 and 69** are directly readable on the elected species.

All the elected claims are readable on the elected species except for claims 18, 19 and 70.

An examination of claims 1-17, 20-69 and 71-92 is respectfully requested.

Respectfully submitted,

*Martin D. Moynihan*

Martin D. Moynihan  
Registration No. 40,338

Date: March 13, 2007